

**10/588498**

1303.46433X00

**AP20 Rec'd PCT/PTO 04 AUG 2006**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicants: C. ISHIKAWA, et al.

Serial No.: NEW

Filed: AUGUST 4, 2006

For: PHOTSENSITIVE RESIN COMPOSITION,  
PHOTSENSITIVE ELEMENT COMPRISING THE SAME,  
PROCESS FOR PRODUCING RESIST PATTERN, AND  
PROCESS FOR PRODUCING PRINTED WIRING BOARD

**PRELIMINARY AMENDMENT**

**Mail Stop: NEW APPS**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

August 4, 2006

Sir:

Please amend the above-identified application, prior to calculation of the filing fee, as listed in the following, and as set forth on the following pages:

AMENDMENTS TO THE CLAIMS; and

REMARKS are included following the amendments.